

Special Issue

Thin Films: Growth and Characterization

Message from the Guest Editors

Dear colleagues, This Special Issue will bring together papers with topics in the field of thin films, more particularly on chemical and physical fabrication methods and technologies for thin film growth and their characterization. Aspects such as surface modifications of substrates used as templates will be also considered. Correlation between microstructural, morphological, and electrical properties will be emphasized based on techniques such as X-ray and electron diffraction, transmission electron microscopy, atomic force microscopy, X-ray, electron or positron spectroscopy, and electrical transport property measurements. A large spectrum of materials and structures are considered, such as semiconductors, superconductors, materials for spintronics, nitrides, ZnO, multiferroics, ferroelectrics, plasmonic materials, transparent conductors, superlattices, nanocrystals, polymers, carbon-based materials, and others. Companies are encouraged to present new products that can be used for any of the above topics.

Guest Editors

Dr. Victor Leca

Department Extreme Light Infrastructure-Nuclear Physics (ELI-NP),
Horia Hulubei National Institute for R&D in Physics and Nuclear
Engineering, Bucharest, Romania

Prof. Dr. Maria Dinescu

INFILPR—National Institute for Laser, Plasma and Radiation Physics,
Magurele, Romania

Deadline for manuscript submissions

closed (20 April 2023)



Materials

an Open Access Journal
by MDPI

Impact Factor 3.2
CiteScore 6.4
Indexed in PubMed



mdpi.com/si/81091

Materials
Editorial Office
MDPI, Grosspeteranlage 5
4052 Basel, Switzerland
Tel: +41 61 683 77 34
materials@mdpi.com

[mdpi.com/journal/
materials](https://mdpi.com/journal/materials)





Materials

an Open Access Journal
by MDPI

Impact Factor 3.2
CiteScore 6.4
Indexed in PubMed



[mdpi.com/journal/
materials](https://mdpi.com/journal/materials)



About the Journal

Message from the Editorial Board

Materials (ISSN 1996-1944) was launched in 2008. The journal covers twenty-five comprehensive topics: biomaterials, energy materials, advanced composites, advanced materials characterization, porous materials, manufacturing processes and systems, advanced nanomaterials and nanotechnology, smart materials, thin films and interfaces, catalytic materials, carbon materials, materials chemistry, materials physics, optics and photonics, corrosion, construction and building materials, materials simulation and design, electronic materials, advanced and functional ceramics and glasses, metals and alloys, soft matter, polymeric materials, quantum materials, mechanics of materials, green materials, general. *Materials* provides a unique opportunity to contribute high quality articles and to take advantage of its large readership.

Editors-in-Chief

Prof. Dr. Maryam Tabrizian

1. Department of Biomedical Engineering, Faculty of Medicine and Health Sciences, McGill University, Montreal, QC H3A 2B6, Canada
2. Faculty of Dentistry and Oral Health Sciences, McGill University, 3640 Rue University, Montreal, QC H3A 0C7, Canada

Prof. Dr. Yuguang Ma

State Key Laboratory of Luminescent Materials and Devices, South China University of Technology, Guangzhou 510640, China

Author Benefits

Open Access:

free for readers, with article processing charges (APC) paid by authors or their institutions.

High Visibility:

indexed within Scopus, SCIE (Web of Science), PubMed, PMC, Ei Compendex, CaPlus / SciFinder, Inspec, Astrophysics Data System, and other databases.

Journal Rank:

JCR - Q2 (Metallurgy and Metallurgical Engineering) /
CiteScore - Q1 (Condensed Matter Physics)